

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/595,856 Confirmation No. 7985
Applicant : Haoshen Zhou et al.
371(c) Date : May 16, 2005
Art Unit :
Examiner :
Customer No. : 00270
Title : NANOCRYSTAL OXIDE/GLASS COMPOSITE
MESOPOROUS POWDER OR THIN FILM, PROCESS FOR
PRODUCING THE SAME, AND UTILIZING THE POWDER
OR THIN FILM, VARIOUS DEVICES, SECONDARY
BATTERY AND LITHIUM STORING DEVICE

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Dear Sir:

In compliance with their duty to disclose under 37 CFR §1.56(a), Applicants and their attorneys enclose a form PTO-1449 and copies of the foreign and other documents listed therein.

The listed references were cited in the International Search Report for International Application No. PCT/JP04/16981 or are related U.S. patent documents.

The Examiner is respectfully requested to consider the cited documents and to make the same of record in the file of the present application.

In the event that a fee for the Information Disclosure Statement is required, please charge the fee to our Deposit Account No. 08-3040.

Respectfully submitted,
HOWSON AND HOWSON
Attorneys for Applicant

By /William Bak/
William Bak
Reg. No. 37,277
501 Office Center Drive
Suite 210
Fort Washington, PA 19034
(215) 540-9216

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| Form PTO-1449 U.S. Patent and Trademark Office INFORMATION DISCLOSURE STATEMENT | Atty. Docket No. OGOSH54USA | Serial No. 10/595,856 |
| | Applicant: Haoshen Zhou et al. | |
| | 371 (c) Date: May 16, 2006 | Group Art Unit: |

U.S. PATENT DOCUMENTS

| Examiner Initial | | Document No. | Date | Name | Class | Subclass |
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Other Documents (including Author, Title, Date, Pertinent Pages, Etc.)

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| Examiner | Date Considered | |

*Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.